

# Semiconductor Parameters

Material	$E_g$ (eV)	$B$ (cm <sup>-3</sup> K <sup>-3/2</sup> )	$n_i$ (cm <sup>-3</sup> ) @ RT
Si	1.1	$5.23 \times 10^{15}$	$1.5 \times 10^{10}$
GaAs	1.4	$2.10 \times 10^{14}$	$1.8 \times 10^6$
Ge	0.66	$1.66 \times 10^{15}$	$2.4 \times 10^{13}$

$k$  - Boltzmann's Constant

$$k = 1.38 \times 10^{-23} \text{ m}^2 \text{ kg s}^{-2} \text{ K}^{-1}$$

$q$  - electron charge

$$q = 1.60 \times 10^{-19} \text{ coulombs} \quad (\text{As})$$

$T$  - Temperature in Kelvin

$$70^\circ\text{F} \rightarrow 21^\circ\text{C} \rightarrow 294\text{K}$$

Typically call Room Temp (RT) 300K (80 °F)

Diffusion coefficient electrons Si  $\leq 36 \text{ cm}^2/\text{s}$

Diffusion coefficient holes Si  $\leq 12 \text{ cm}^2/\text{s}$

Mobility electrons Si  $\leq 1400 \text{ cm}^2 / \text{V s}$

Mobility holes Si  $\leq 450 \text{ cm}^2 / \text{V s}$